

Optical Waveguides fabricated by combination of ink-jet and flexographic printing

P. Bollgrün^{1,3}, T. Wolfer², U. Gleissner³
D. Mager¹, C. Megnin³
T. Hanemann^{3,4}, L. Overmeyer², J. Korvink¹

¹⁾ Institute of Microstructure Technology (IMT) - Karlsruhe Institute of Technology (KIT)

²⁾ Institute of Transport- and Automation Technology (ITA) - University Hanover

³⁾ Department of Microsystems Technology (IMTEK) - Universität Freiburg

⁴⁾ Institute for Applied Materials (IAM) - Karlsruhe Institute of Technology (KIT)

1. Motivation & Research environment
2. Flexo-printed optical waveguides
3. Ink-jet printed optical waveguides
4. Combination of both techniques
5. Next Steps
6. Printing of fluorescent elements

Motivation and Research Environment

All-optical
sensor
networks on
flexible foil
substrates



PlanOS
SFB/TRR 123

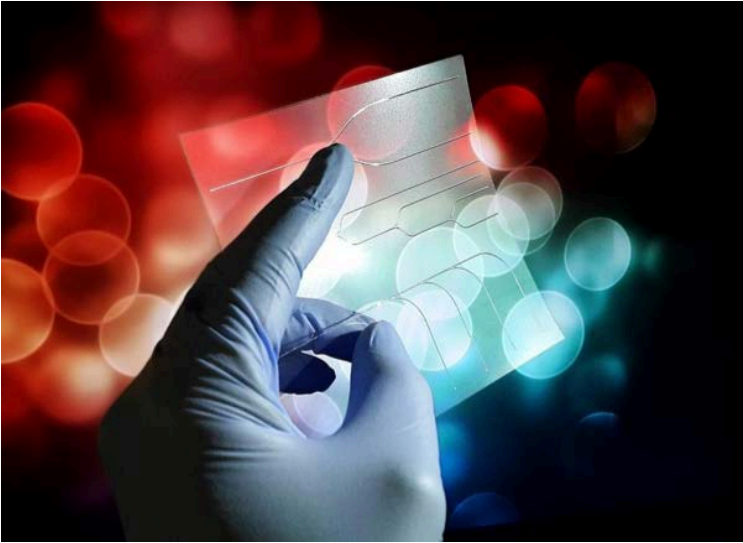
HOT - Hannoversches Zentrum für optische Technologien

IMTEK - Institut für Mikrosystemtechnik



created by
additive
mass
fabrication
of polymers

Applications for Planar Optronic Sensors

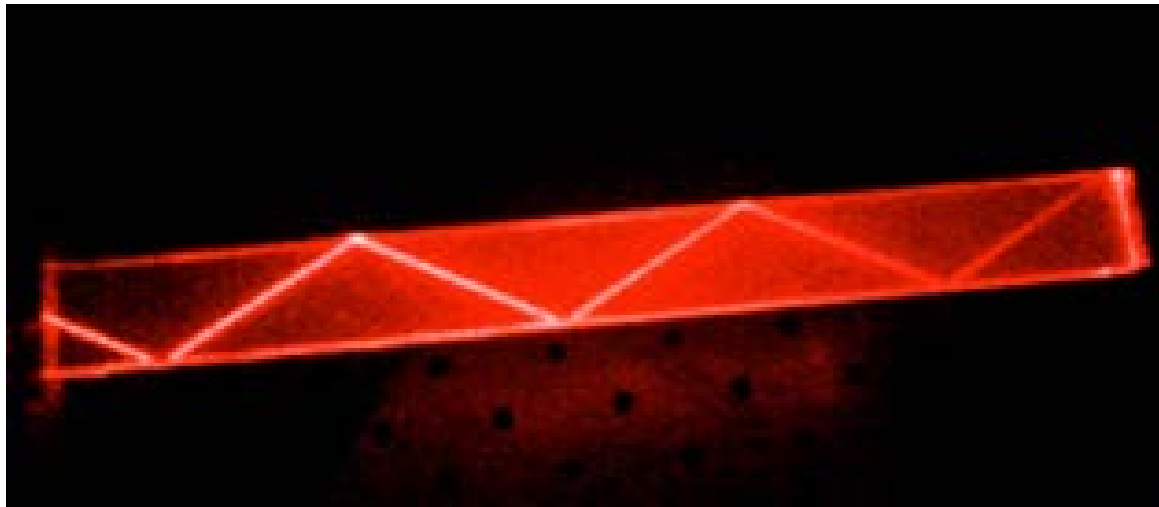


T. Wolfer, ITA Hannover



A high refractive index causes
total internal reflection.

Light can be confined and guided!



PMMA guiding a red laser beam

Requirements:

Low interface roughness

High transparency

Why Printing?

- Liquid materials allow effortless creation of optical structures
- Printing typically aims to cheap mass-production
- Polymers are established for printing techniques



Water on glass = microlenses

Can optical waveguides on foils be fabricated by printing techniques?

Investigated Techniques:

Flexographic printing

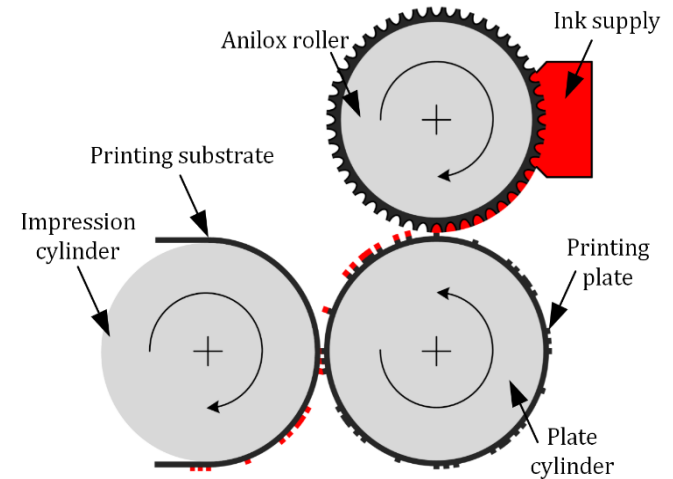
Ink-jet printing

Is a combination of both techniques feasible?

Flexo-printed optical waveguides

Flexographic Printing (Tim Wolfer, ITA Hannover)

- High-throughput (1 sheet of 350*500 cm per second)
- Printed pattern defined by printing plate
- Ink: Commercial acrylate varnish from Jaenecke-Schneemann Druckfarben) (viscosity: 200 – 250 mPas)



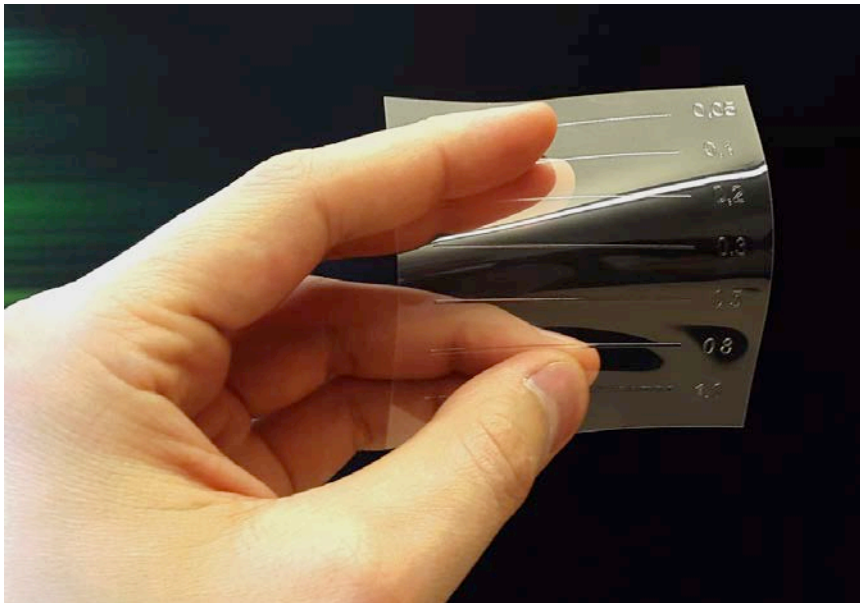
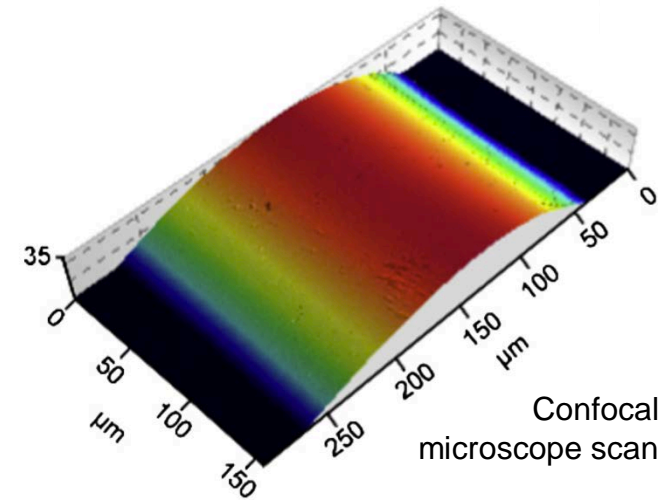
Heidelberger Speedmaster SM 52
(Heidelberger Druckmaschinen AG)

Flexo-printed optical waveguides (Tim Wolfer, ITA Hannover)

No pre-treatment, printing at room temperature under normal air

Printing Cycles: 10

Post-treatment IR+UV, each layer



T. Wolfer, ITA Hannover

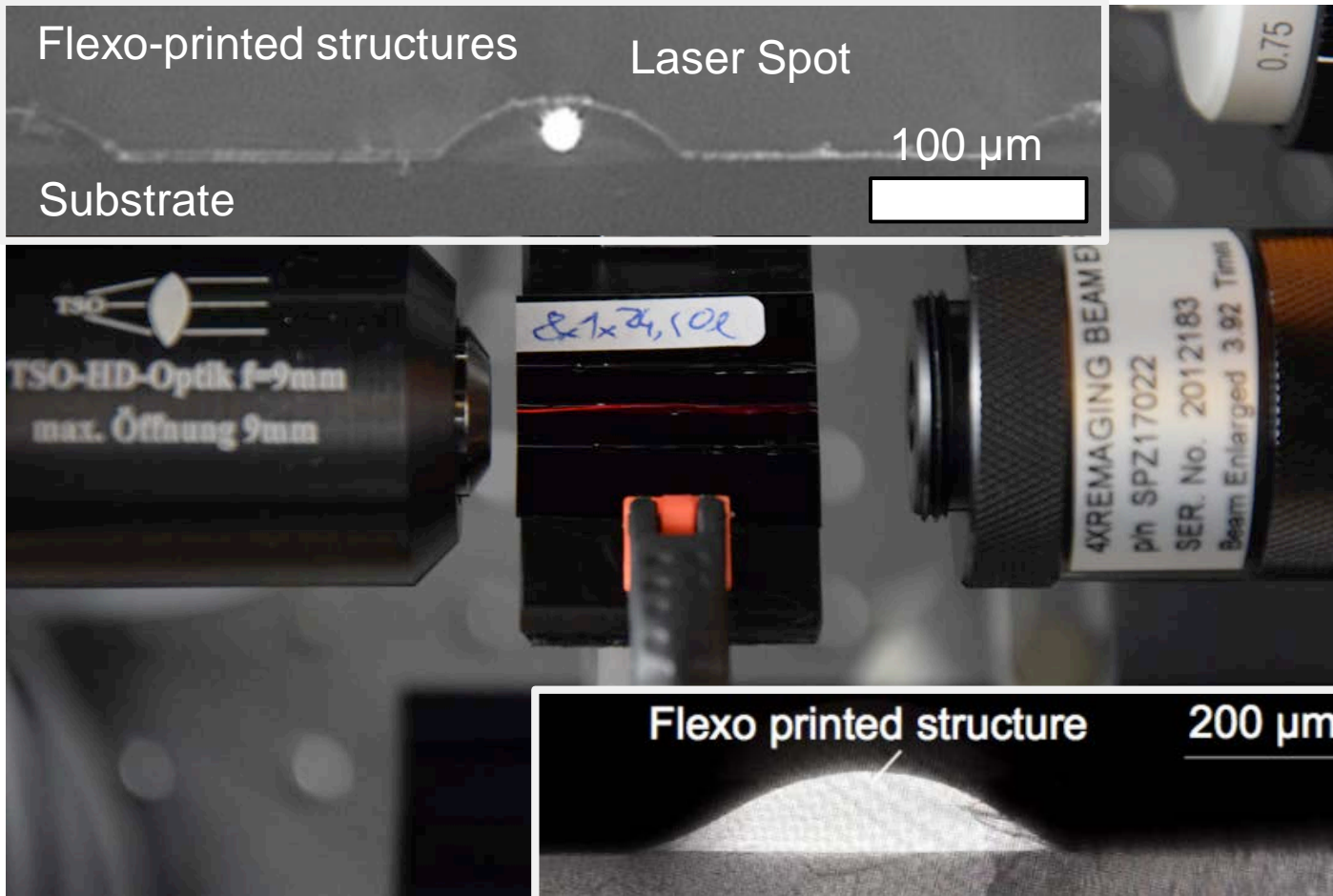
Width: 100 μm - 1000 μm

Height: 4 μm - 110 μm

Surface Roughness: 40 nm

Attenuation: 0.5 dB/cm

Optical Characterization



CW-Laser @
638
nm, 140mW

Camera at
back facet.

Integration
sphere for
power
measurement

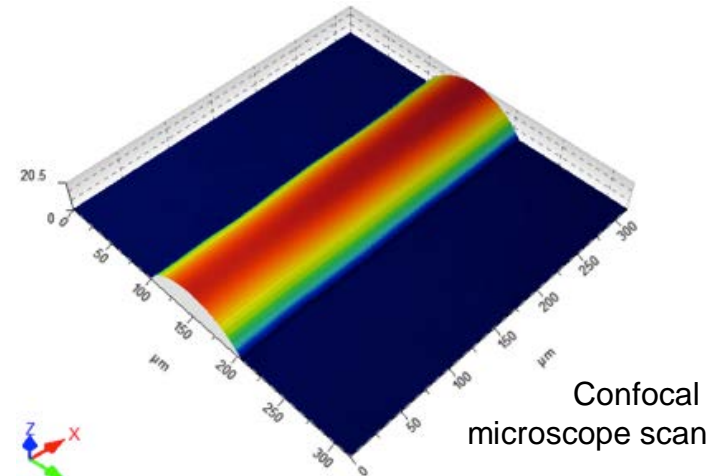
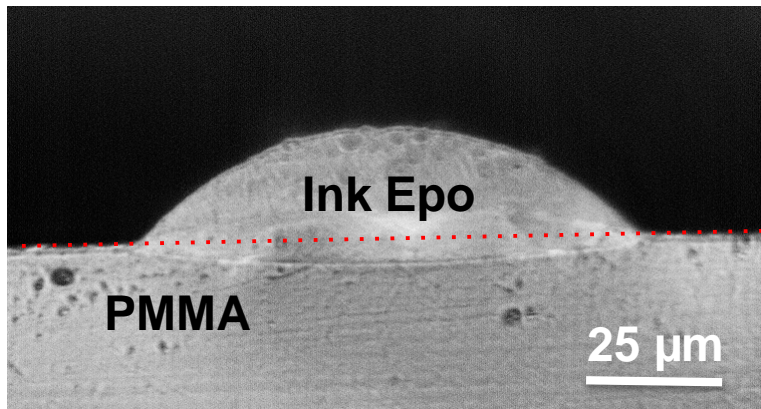
Cutback-
method to rule
out coupling
losses

T. Wolfer, ITA Hannover

Ink-jet printed optical waveguides

Ink-jet printed optical waveguides

Material: InkEpo
Pre-treatment: None
Substrate T
during Printing: 60° C – 75° C
for edge pinning
Printing Cycles: 20 layers
Post-treatment: 60° C for 1h,
2 J @ 365nm



Width: 75 μm - 200 μm

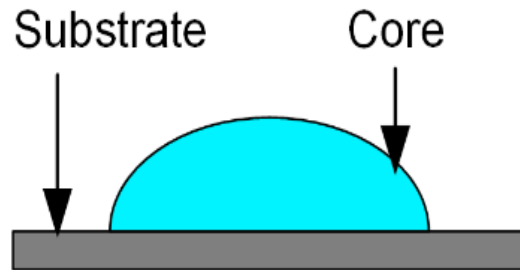
Height: 5 μm - 40 μm

Surface roughness:
<100nm, depending on ink

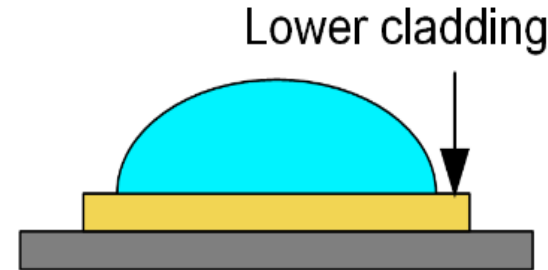
Attenuation:
Typically 5 dB/cm

Combining both methods

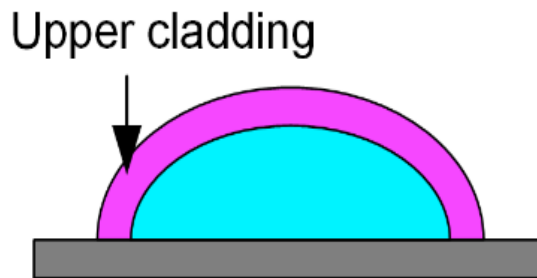
Combination of Flexo- and Inkjet



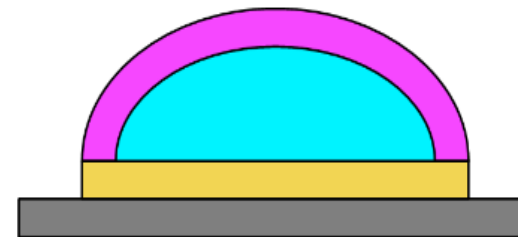
Class 1



Class 2



Class 3

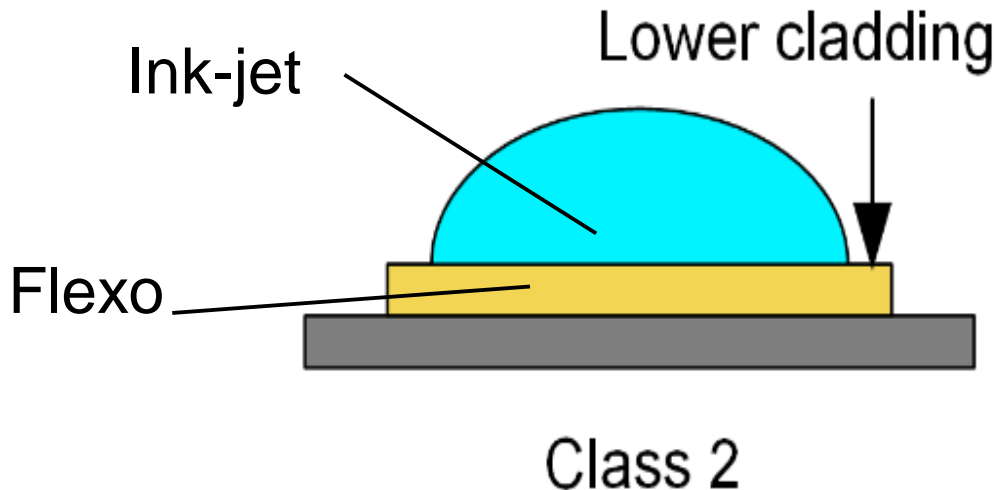


Class 4

Possible waveguide concepts by combining the core and cladding layers (Wolfer, ITA Hannover).

Combination of Flexo- and Inkjet

Core is the new cladding!



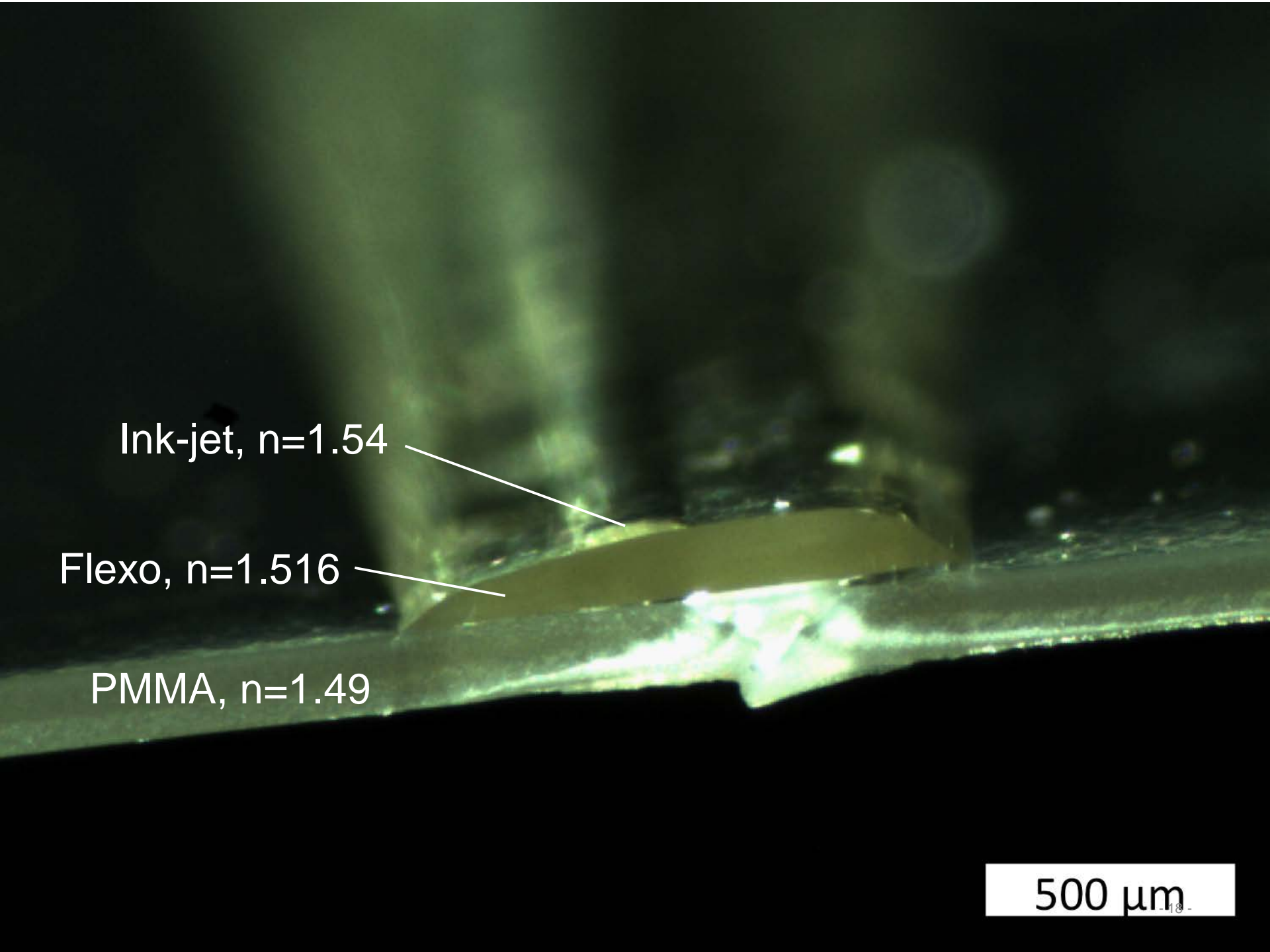
Material: InkEpo

Pre-treatment: Plasma for 60s

Substrate T
during Printing: 60° C

Printing Cycles: 12 Layers

Post-treatment 60° C for 1h,
20 J at 365 nm

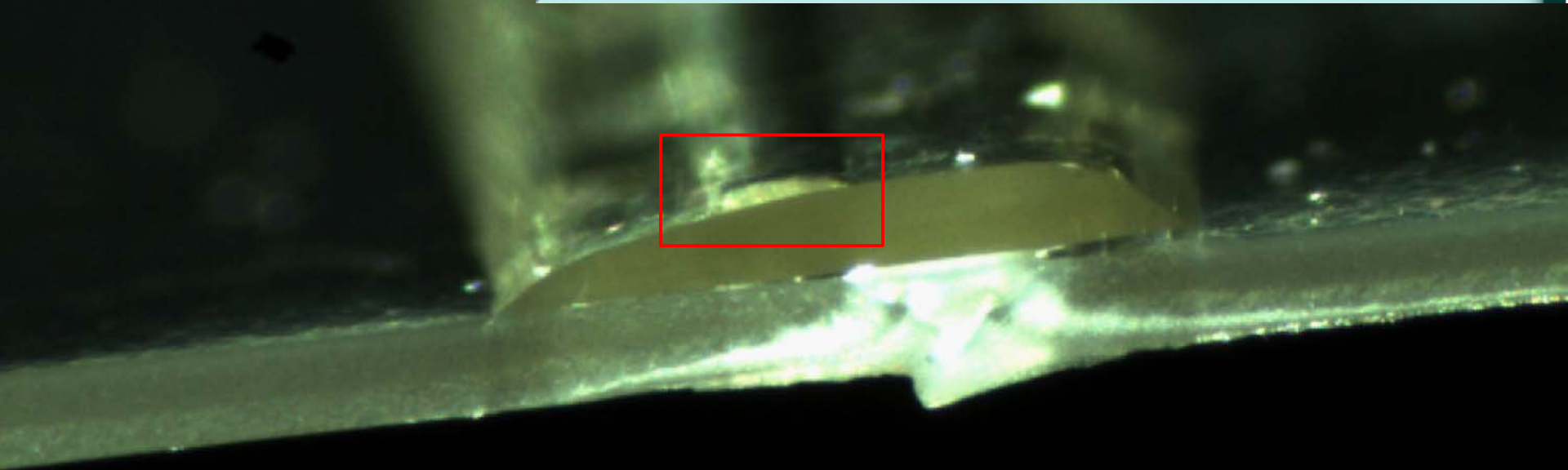
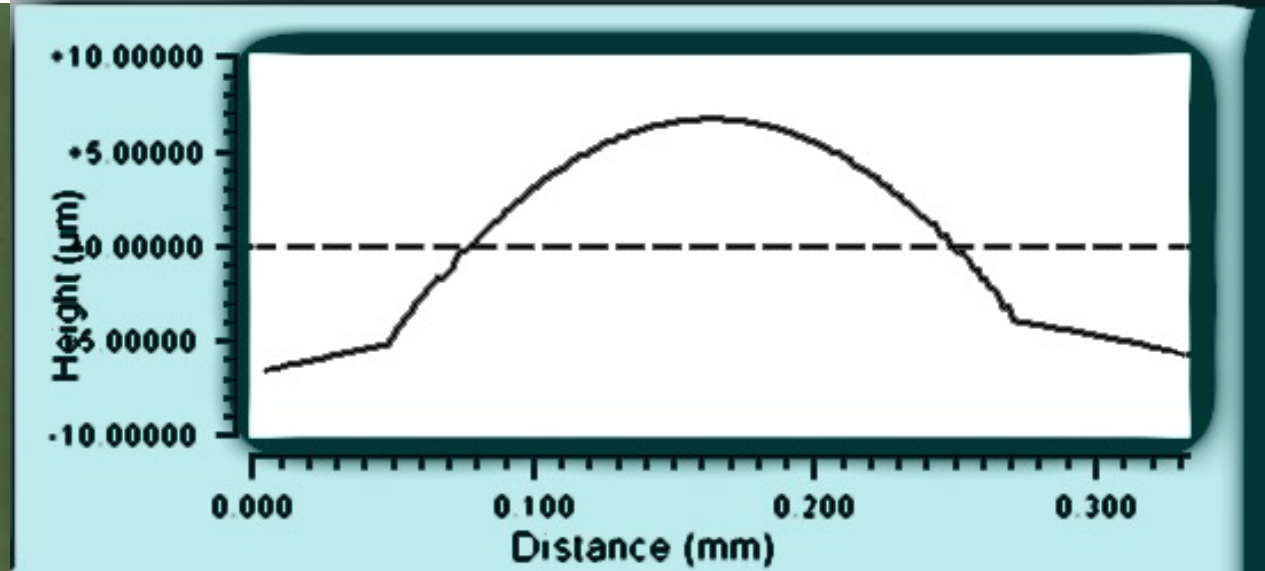


Ink-jet, $n=1.54$

Flexo, $n=1.516$

PMMA, $n=1.49$

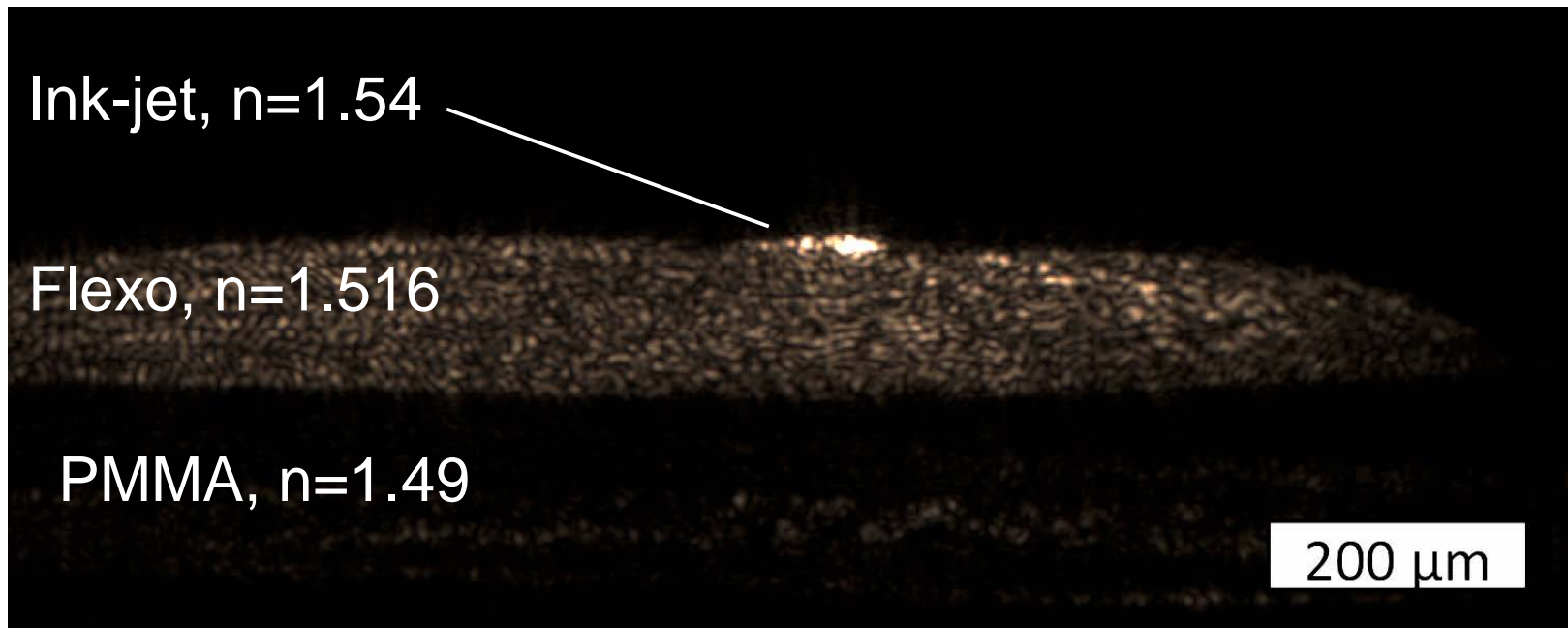
500 μm

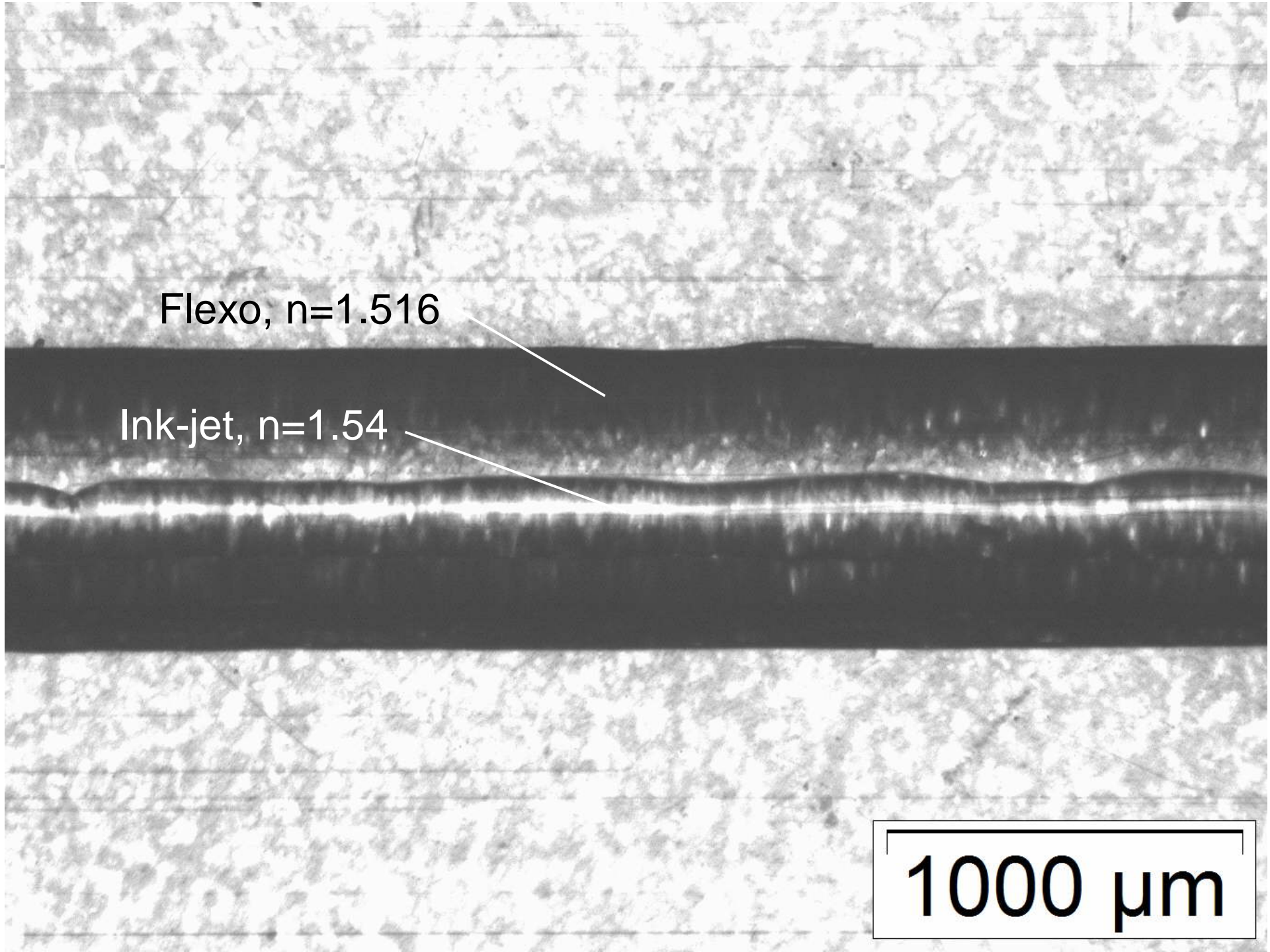


Width: 200 µm
Height: 10 µm

500 µm

Waveguide?





A cross-sectional micrograph showing a layered structure. The top and bottom layers are light gray with a granular texture. The middle section consists of a dark gray layer and a thin, bright white layer. The dark gray layer has a wavy, undulating top surface. Two white lines point from the text labels to the dark gray layer and the white layer.

Flexo, $n=1.516$

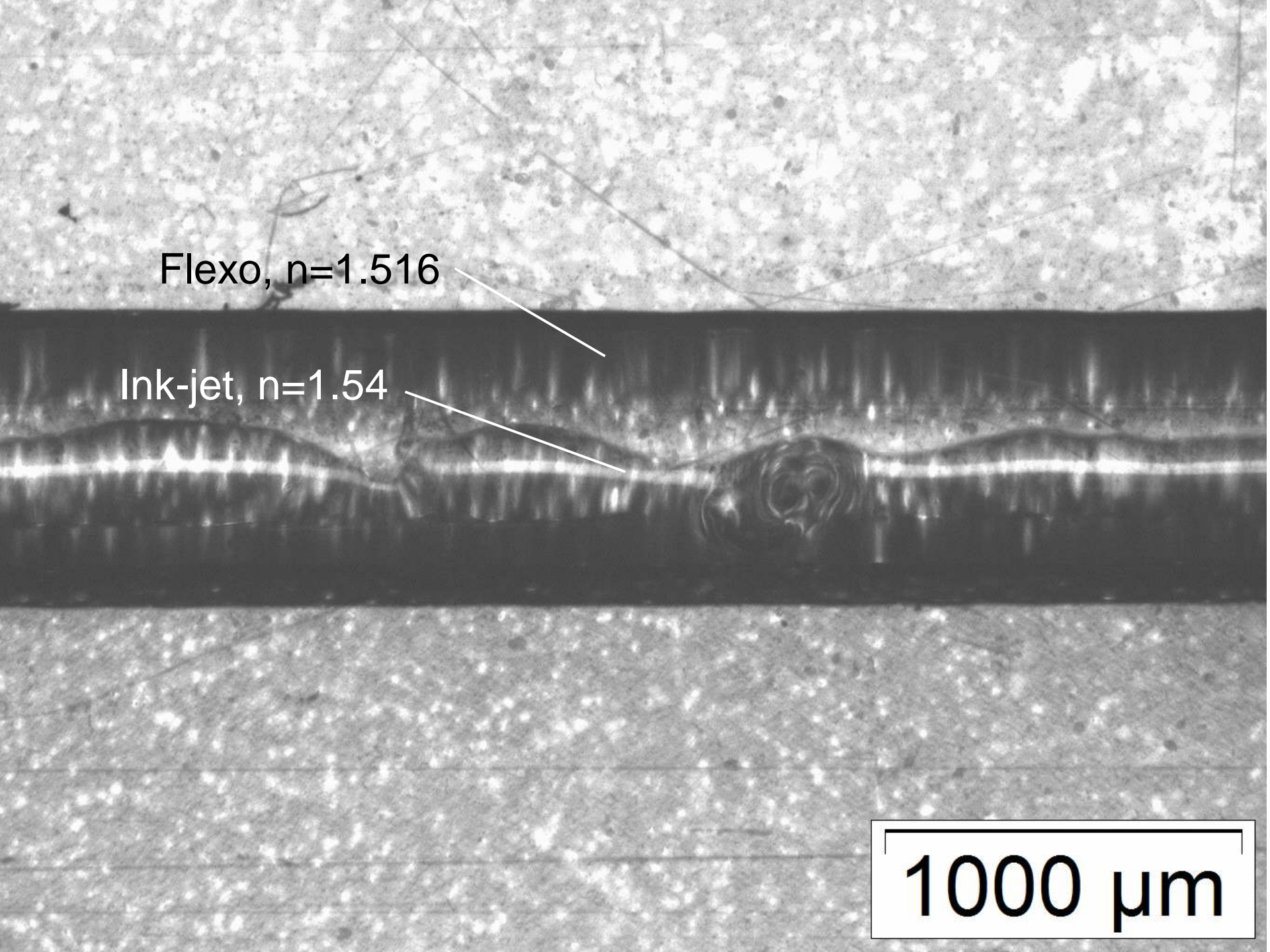
Ink-jet, $n=1.54$

1000 μm

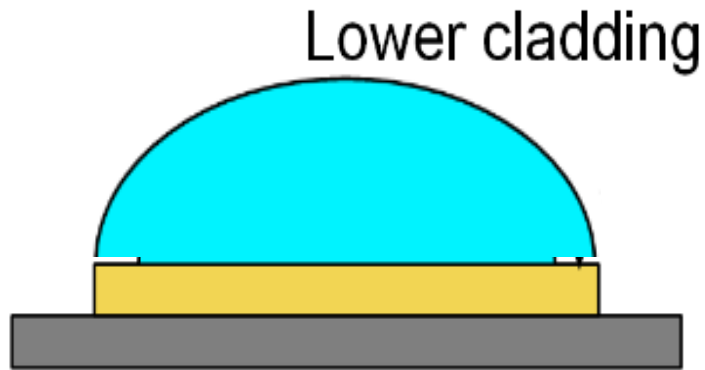
Flexo, $n=1.516$

Ink-jet, $n=1.54$

1000 μm



Alternative Method: Edge Pinning!



Class 2

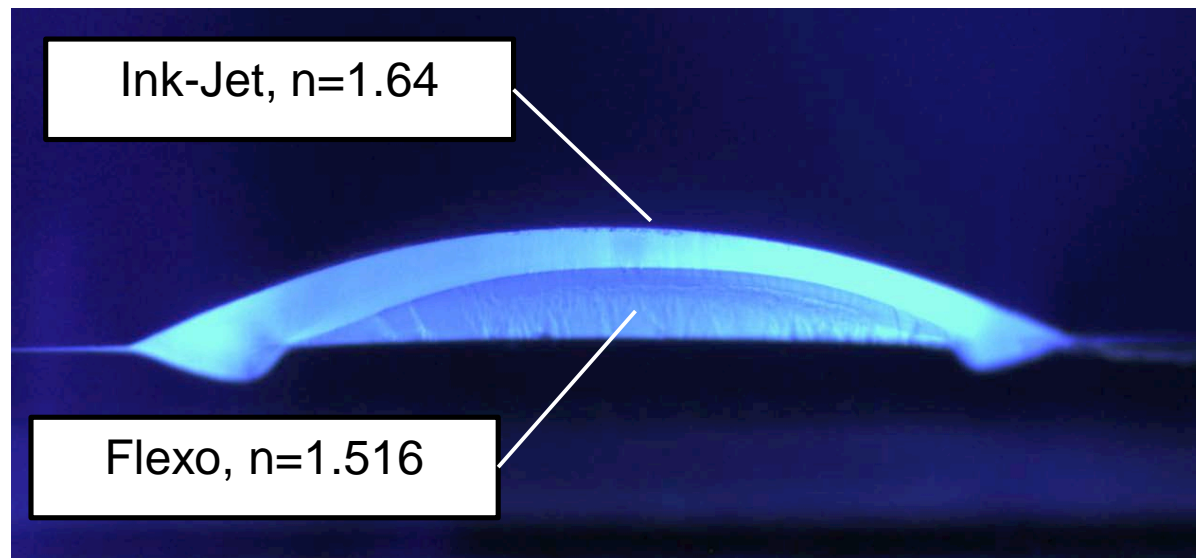
Material: UG 164

Pre-treatment Plasma for 60s

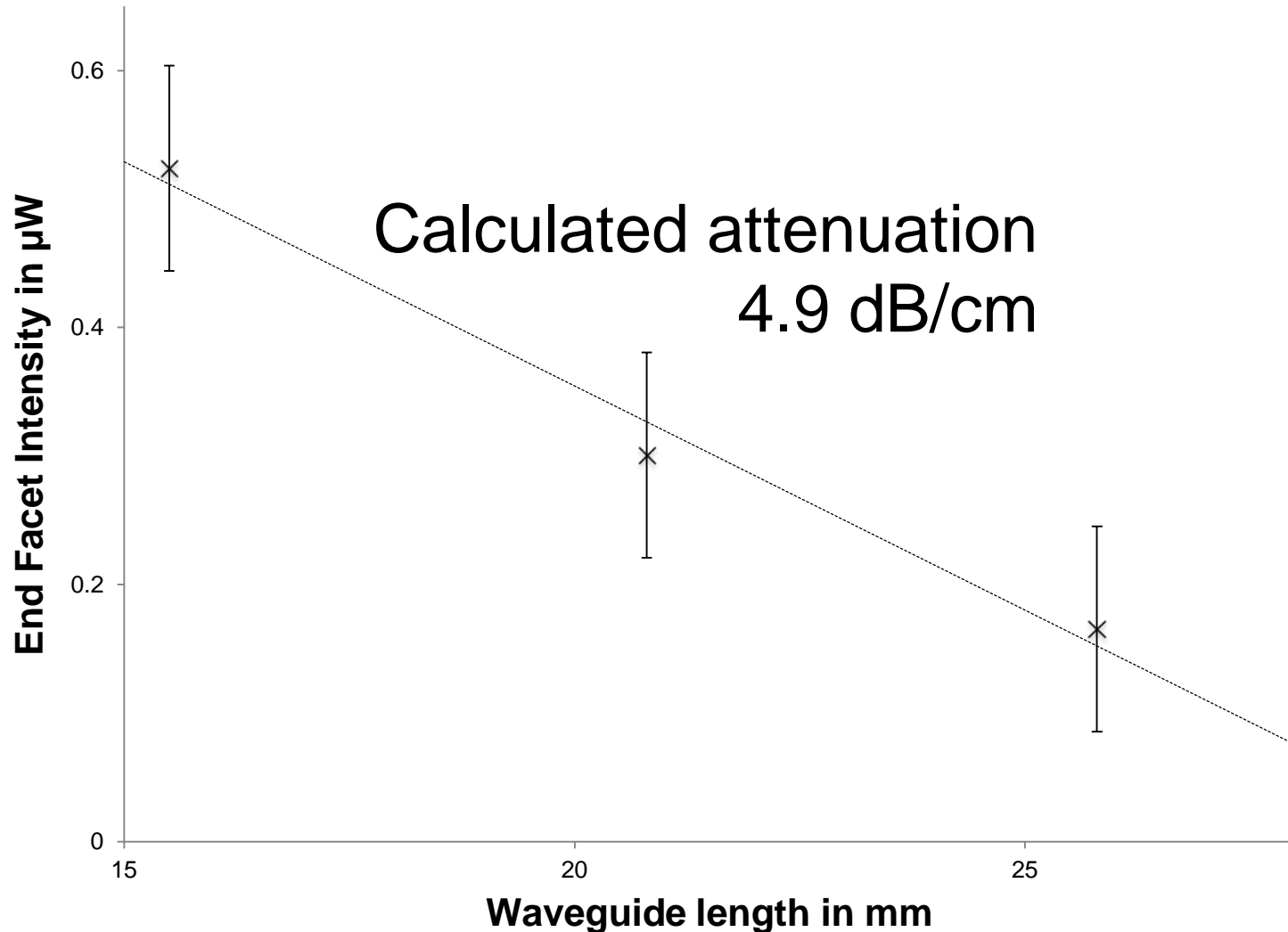
Substrate T
during Printing 60° C

Printing Cycles: 24 Layers

Post-treatment: 20 J at 365 nm



Attenuation measurement by cut-back

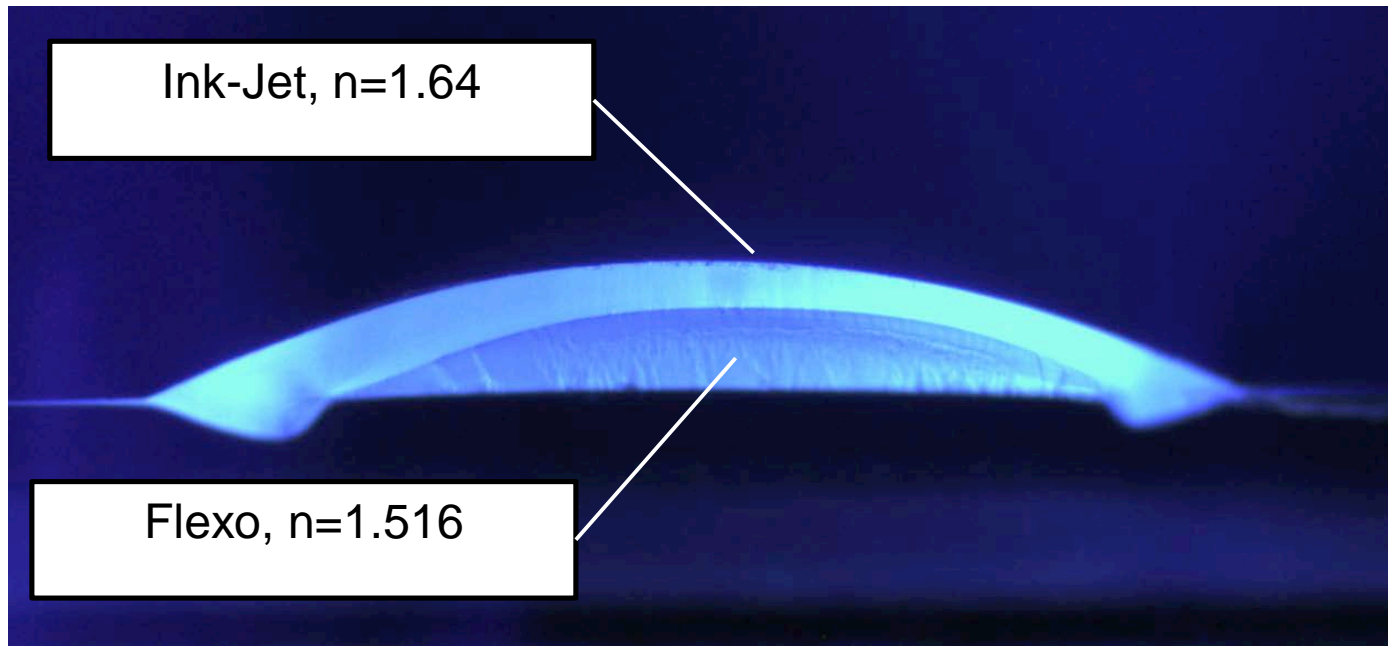


Possible Reasons for Attenuation

High Attenuation, similar as Ink-jet printing

Same diffusion into foil as seen at ink-jet printed waveguides.

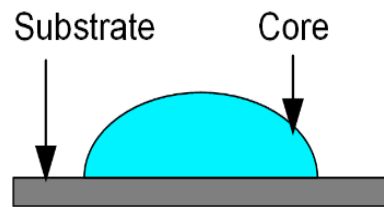
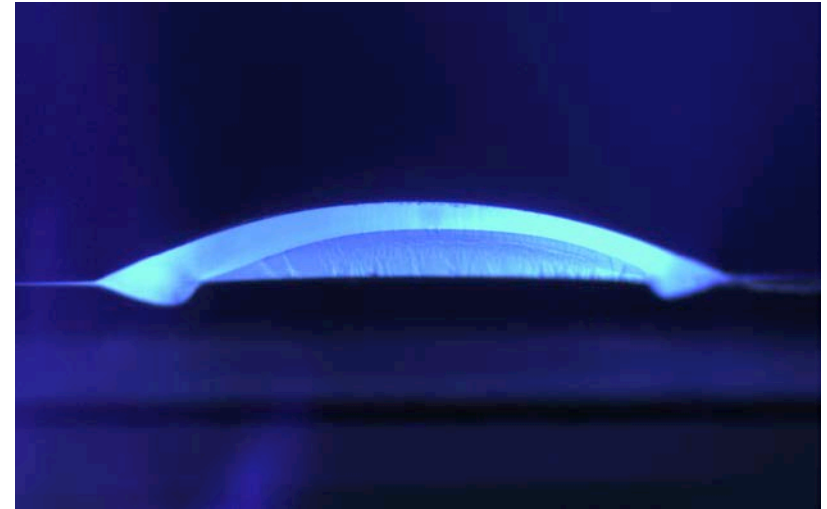
Explanation for high attenuation



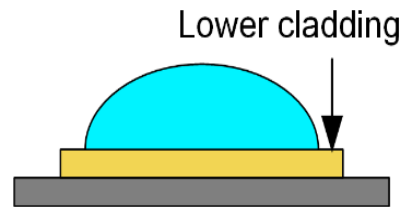
Next Steps

Combination of Flexo- and Inkjet

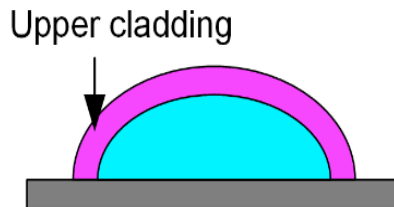
Class 2? Or Class 3?



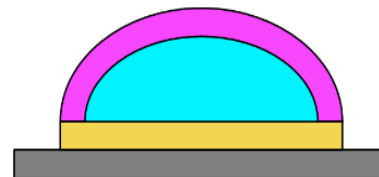
Class 1



Class 2



Class 3



Class 4

Next Step
Class 3 Waveguide
with lower refractive
index

Can optical waveguides on foils be fabricated by printing techniques?

Investigated Techniques:

Flexographic printing **Yes!**

Ink-jet printing (but Ink-jet has
high attenuation)

Is a combination of both techniques feasible?

Not yet

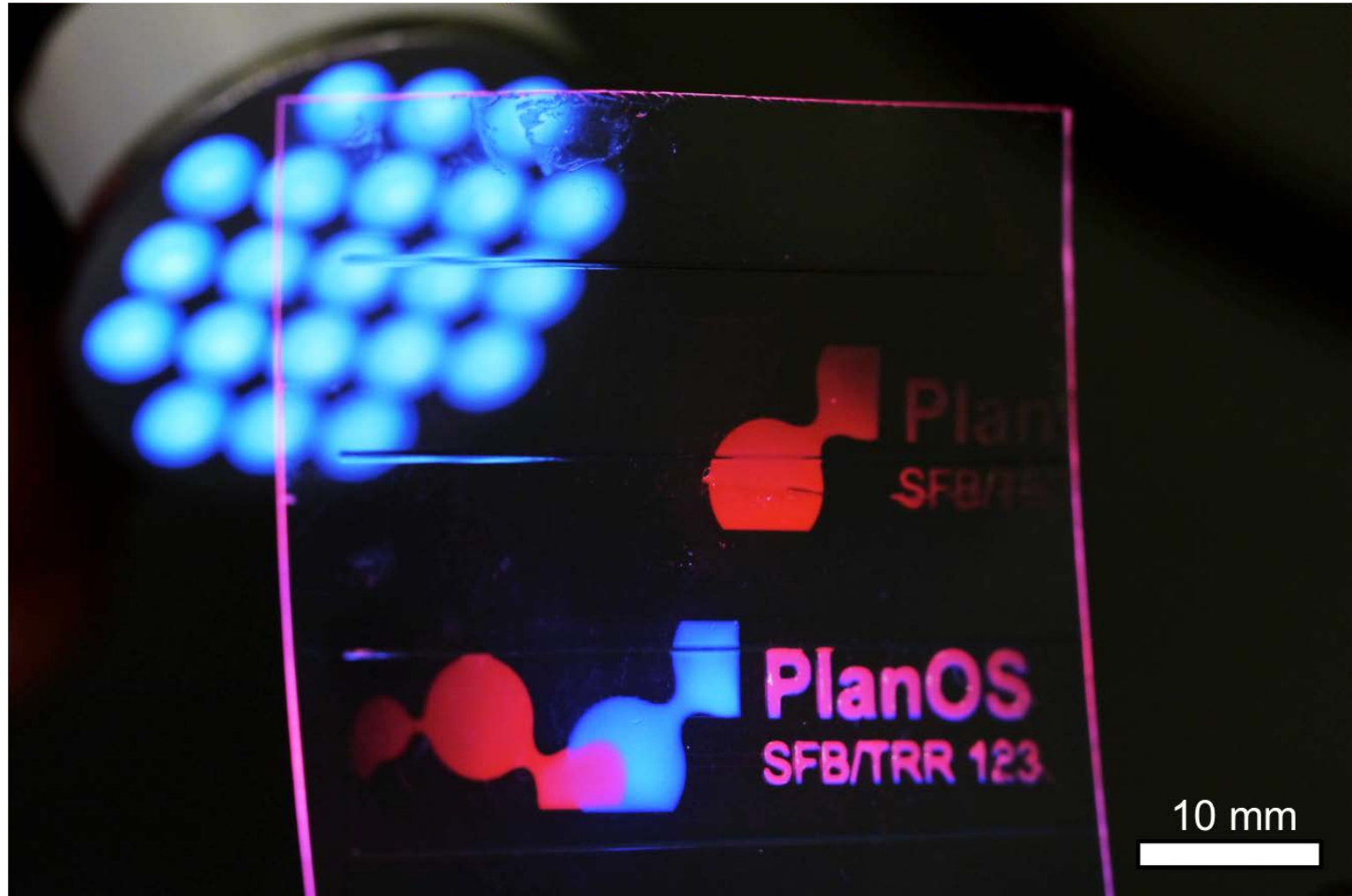
Ink-jet printing – Available Inks



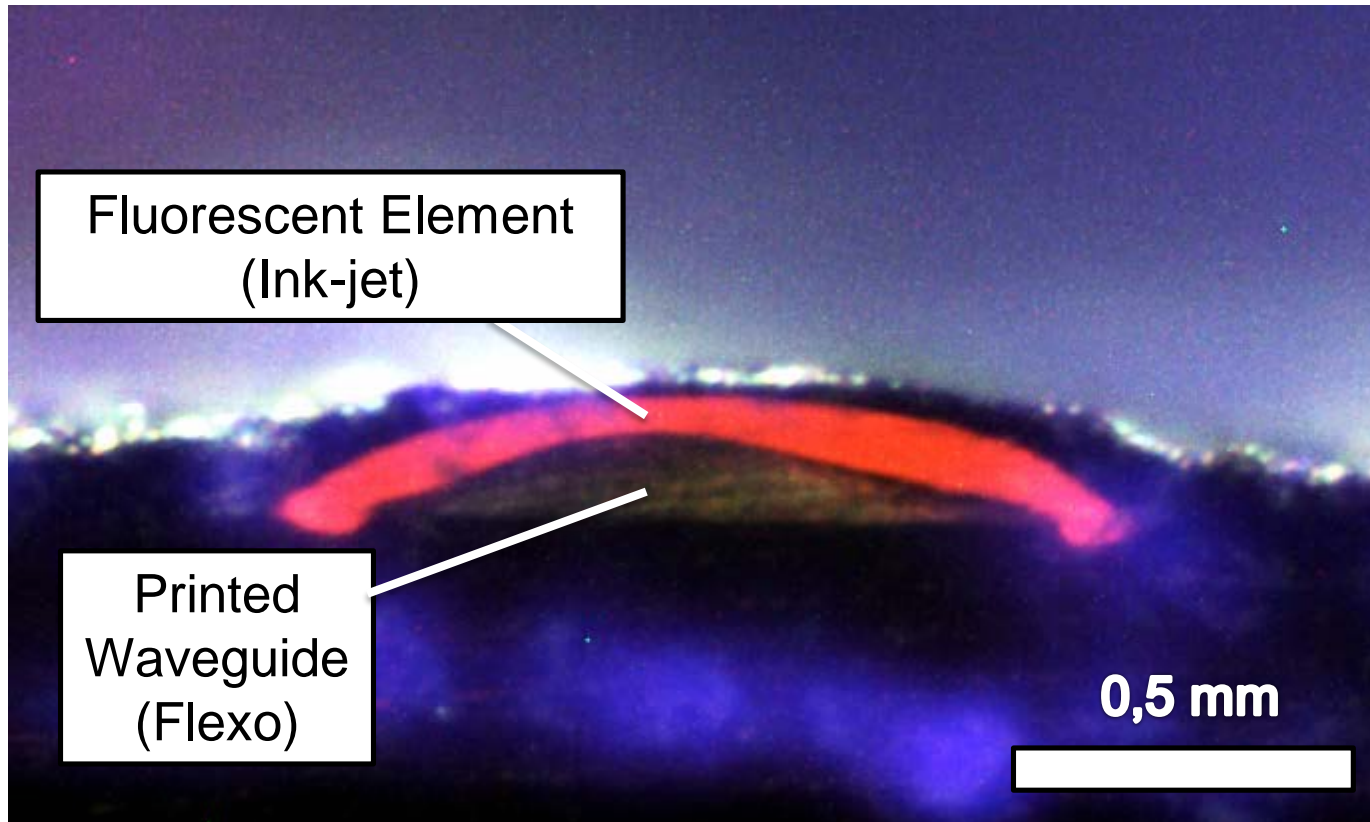
Ink Name	Manufacturer	Solvent	Purpose	Comments
InkEpo	Microresist Technology	GBL (Evaporates)	Waveguides	Volatile and aggressive solvent
InkOrmo				
UGS70E	IMTEK, Prof Hanemann, Uwe Gleissner	EGDMA (Polymerizes)		Scattering dots after polymerisation
UG164				
Europium-Ink			Light Emission	405 nm → 612 nm
Antracene-Ink				365 nm → 430 nm

Printing of fluorescent elements

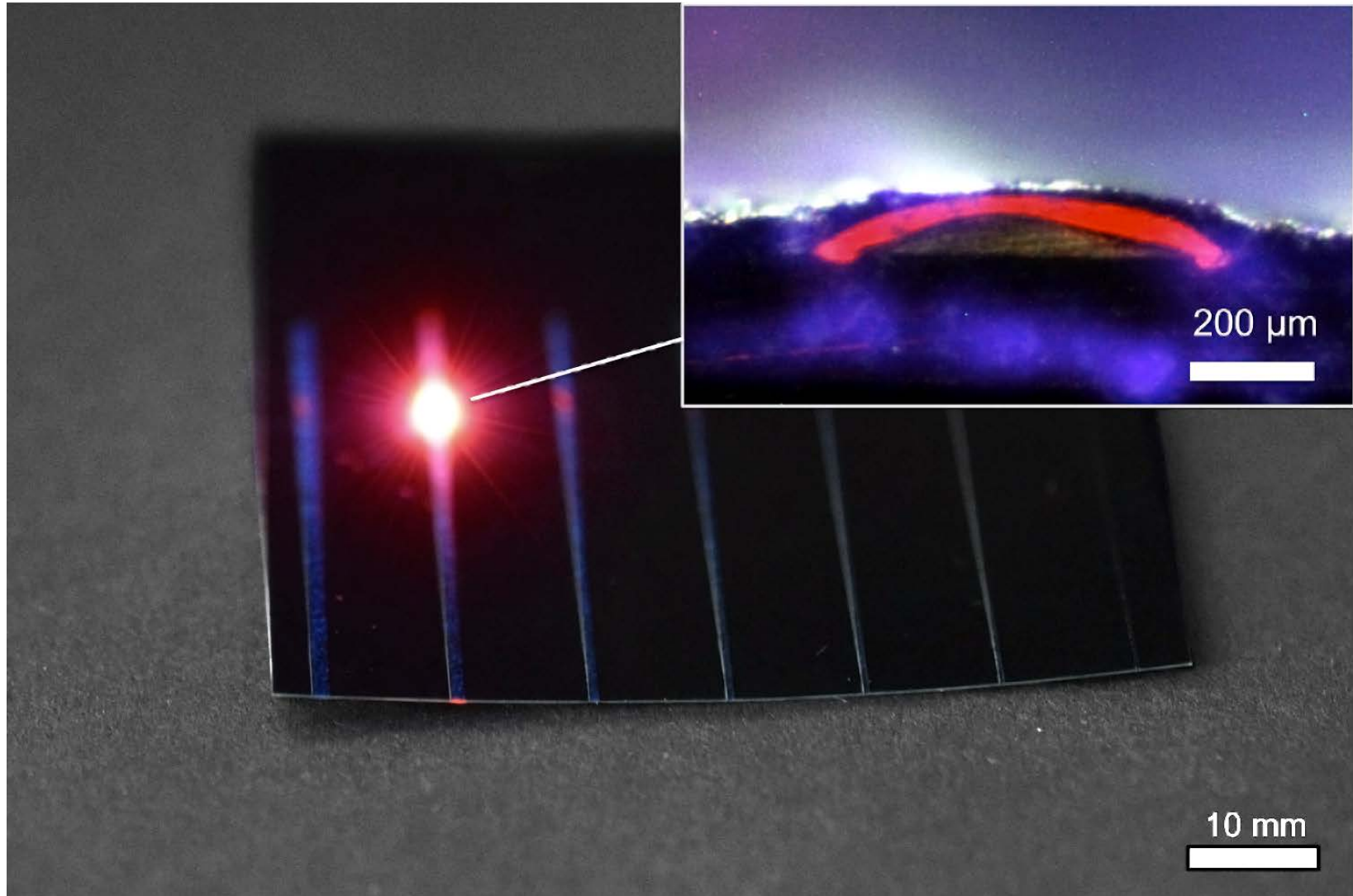
Fluorescence



Fluorescence



Fluorescence



Thank you for your attention



Thanks to
for funding

DFG Deutsche
Forschungsgemeinschaft



PlanOS
SFB/TRR 123

UNI
FREIBURG

Prevent ink mixing with substrate

- Polymerize between layers
- Guide Ink by conditioning lines or grooves in the substrate
- Switch to chemically more stable substrate like PET